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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/988,962	11/19/2001	Hiroshi Tanabe	NECR 19.194	9667
26304	7590 06/23/2003			
KATTEN MUCHIN ZAVIS ROSENMAN			EXAMINER	
575 MADISON AVENUE NEW YORK, NY 10022-2585			ECKERT II, GEORGE C	
			ART UNIT	PAPER NUMBER
			2815	
			DATE MAILED: 06/23/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No. **09/988,962**

Applicant(s)

Tanabe et al.

Examiner

George C. Eckert II

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	The MAILING DATE OF this communication appears t	on the cover sheet with the correspondence address			
	for Reply				
	ORTENED STATUTORY PERIOD FOR REPLY IS SET	TO EXPIRE 3 MONTH(S) FROM			
THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136 (a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the					
•	g date of this communication. period for reply specified above is less than thirty (30) days, a reply within th	e statutory minimum of thirty (30) days will be considered timely.			
- If NO	period for reply is specified above, the maximum statutory period will apply a to reply within the set or extended period for reply will, by statute, cause th	nd will expire SIX (6) MONTHS from the mailing date of this communication.			
- Any re	ply received by the Office later than three months after the mailing date of the				
Status	patent term adjustment. See 37 CFR 1.704(b).				
1) 💢	Responsive to communication(s) filed on Apr 22, 20				
2a) 🗆	This action is FINAL . 2b) 💢 This acti	ion is non-final.			
3) 🗆	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11; 453 O.G. 213.				
Disposi	tion of Claims				
4) 💢	Claim(s) 1-24	is/are pending in the application.			
4	a) Of the above, claim(s) 3-24	is/are withdrawn from consideration.			
5) 🗆	Claim(s)	is/are allowed.			
6) 💢	Claim(s) 1 and 2	is/are rejected.			
7) 🗆	Claim(s)	is/are objected to.			
8) 🗆		are subject to restriction and/or election requirement.			
Applica	ition Papers				
9) 🗆	The specification is objected to by the Examiner.				
10)💢	The drawing(s) filed on Nov 19, 2001 is/are	a) 💢 accepted or b) 🗆 objected to by the Examiner.			
	Applicant may not request that any objection to the d	rawing(s) be held in abeyance. See 37 CFR 1.85(a).			
11)	The proposed drawing correction filed on	is: a) \square approved b) \square disapproved by the Examiner.			
	If approved, corrected drawings are required in reply t	to this Office action.			
12)	The oath or declaration is objected to by the Exami	ner.			
Priority under 35 U.S.C. §§ 119 and 120					
13)💢	13) Acknowledgement is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).				
a) ☑ All b) ☐ Some* c) ☐ None of:					
	1. $\[egin{array}{cccccccccccccccccccccccccccccccccccc$	e been received.			
	2. Certified copies of the priority documents have been received in Application No.				
*0	application from the International Bure				
	ee the attached detailed Office action for a list of the				
_	Acknowledgement is made of a claim for domestic				
_	☐ The translation of the foreign language provisional				
15) L	Acknowledgement is made of a claim for domestic	priority under 35 0.3.6. 33 120 and/or 121.			
Attachment(s) 1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413) Paper No(s)					
	otice of Draftsperson's Patent Drawing Review (PTO-948)	5) Notice of Informal Patent Application (PTO-152)			
	3) Note: 11 Information Disclosure Statement(s) (PTO-1449) Paper No(s). 2 6) Other:				

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DETAILED ACTION

Election/Restriction

1. Applicant's election without traverse of the Group I invention (claims 1 and 2) is acknowledged. Claims 17-24 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim. Election was made without traverse in Paper No. 7.

Priority

2. Receipt is acknowledged of papers submitted under 35 U.S.C. 119(a)-(d), which papers have been placed of record in the file.

Claim Rejections - 35 U.S.C. § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in-
- (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effect under this subsection of a national application published under section 122(b) only if the international application designating the United States was published under Article 21(2)(a) of such treaty in the English language; or
- (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that a patent shall not be deemed filed in the United States for the purposes of this subsection based on the filing of an international application filed under the treaty defined in section 351(a).
- 3. Claims 1 and 2 are rejected under 35 U.S.C. 102(e) as being anticipated by US 6,177,301 to Jung. Jung teaches, with reference to figures 6 and 7A, a thin film transistor comprising: an insulating substrate (not shown, see col. 5, lines 41-44);

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a polycrystalline silicon island 61 formed on said insulating layer, a grain size of the polycrystalline silicon island being elongated along one direction (see figure 7A, the grains 73 elongated across the page); and

a source region 71, a channel region 74 and a drain region 72 arranged in said polycrystalline silicon island in parallel with the direction.

With regard to claim 2, Jung teaches that the insulating substrate may comprise a glass substrate (col. 4, lines 25-26).

Conclusion

4. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. The additional references teach a polycrystalline layer formed having a grain size elongated parallel to the source, drain and channel (Ogawa fig. 5, Unagami col. 6, line 63).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to George C. Eckert II whose telephone number is (703) 305-2752.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mr. Eddie Lee can be reached on (703) 308-1690. The fax number is (703) 308-7722.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0956.

GCE June 17, 2003 GEORGE ECKERT
PRIMARY EXAMINER